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PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:

Attorney Docket No.: 2950.01US02

Kambe et al.

Confirmation No.: 6755

Application No.: 09/841,255

Examiner: Koslow, C.

Filed: April 24, 2001

Group Art Unit: 1755

For: ABRASIVE PARTICLES FOR SURFACE POLISHING

AMENDMENT AFTER FINAL

Box AF  
Assistant Commissioner for Patents  
Washington, D.C. 20231

OFFICIAL  
FAX RECEIVED

DEC 19 2002

GROUP 1700

Sir:

In response to the Final Office Action of October 28, 2002, amendment to the above-identified patent application is respectfully requested. Replacement claims are presented below and marked-up claims are presented on separate sheets at the end of the amendment.

In the Claims

Please substitute the following amended claims for those currently pending:

C1  
15. (Amended) A polishing composition comprising a dispersion of particles, the particles comprising metal compounds or silicon compounds with an average particle diameter from about 5 nm to about 50 nm, wherein less than about 1 particle in  $10^6$  has a diameter greater than about five times the average diameter.

REMARKS

Claims 1-4, 6-10, 12-15 and 23-25 are pending. By this Amendment, claim 15 has been amended. The amendment to claim 15 is supported by the specification, for example,